



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

November 13, 2025

IGI Report Number

LG749518113

Description

LABORATORY GROWN DIAMOND

Shape and Cutting Style

MARQUISE BRILLIANT

Measurements

13.58 X 6.51 X 4.06 MM

GRADING RESULTS

Carat Weight

2.04 CARATS

Color Grade

E

Clarity Grade

VVS 2

ADDITIONAL GRADING INFORMATION

Polish

EXCELLENT

Symmetry

EXCELLENT

Fluorescence

NONE

Inscription(s)

 LG749518113

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.
Type IIa

Report verification at igi.org

PROPORTIONS

Medium To Slightly Thick (Faceted)

14.5%

43%

58%

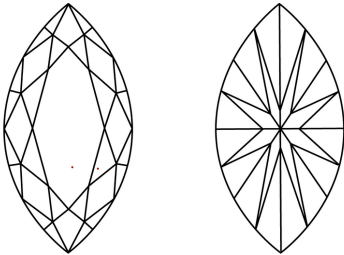
62.4%

Pointed



Sample Image Used

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.

Green symbols indicate external characteristics.

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Culet

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